1. FEATURE

FSR-8000 11G / HA-8000 series adopts a unique formulation resulting a matt coating surface with low reflection factor. Other than the inheritance of all the functional properties of FSR-8000 10G model, its even fine particle size and fine modified resin powder appearance matt coating surfaces are extremely contributive to the soldering process in which solder balls are inhibited from sticking to the coating surfaces hence achieves a perfect solder result which coincides with the requirements of the US and Europe markets.

FUNCTION & CHARACTERISTICS



2.SPECIFICATION

CV Number 11G 56 / 11G 58 / 11G SG

| Color | |
|------------------------------|---|
| Base FSR-8000 | green |
| Hardener HA-8000 HD80 W8 | white |
| Mixing ratio | 3 : 1 (Base : Hardener) |
| Solid content | 79 wt % |
| Viscosity | 220dPa.s (VT-04,25°C) |
| Specific gravity | 1.3 |
| Ignition point | 76 °C |
| Film hardness | 6H |
| Solder heat resistance | 260°C \times 30sec or longer |
| Hot air leveler resistance | 260°C × 10sec, \geq 3 times |
| Insulation resistance | $\geq 10^{14} \Omega$ |
| Electroless Ni/Au Resistance | Ni: 5 μ m Au: 0.05 μ m |
| Electro Ni/Au Resistance | Ni: 5-8 µm Au: 1.5 µm |
| Pot life at 20°C | 24 hours |
| Shelf life at 25°C | 6 months |
| Packaging | 1 kg (Base750g+Hardener 250g) ;10sets/box |
| Flammability | UL 94V-0 (290°C×30sec) |



3. EXAMPLE OF OPERATION PROCESS

Ink Mixing

The Main component and Harden agent must be mixed throughly before use in the ratio of 3:1 Mixing time 5~10 min. holding time 20~30 min.

Pretreatment

Mechanical brushing or acid treatment

Screen printing

a. Use nylon , polyester or stainless

- steel screen for printing.
- b. 90 ~ 150 mesh/inch
- c. Rubber/Polyurethane (pu)Squeege with the hardness of 60 ~ 70
- d. Printing Angle 60~75°
- e. Film thickness : Wet film 30~40 um Dry film 15~25 um

Precure

First side 75° C × 15 ~ 20 min Second side 75° C × 30 ~ 35 min Both side cure at the same time: 75° C × 30 ~ 55 min

Exposure

Energy required from UV rays: $400 \sim 600$ mj/ cm² Photographic sensitivity : $300 \sim 500$ nm (Photosensitivity : $9 \sim 12$ step)

Developing

By1%~1.2% sodium carbonate (Na₂CO₃) solution Spraying pressure : $1.5 \sim 2.5$ kg/ cm² Temperature : $28 \sim 32^{\circ}$ C Time : $60 \sim 90$ sec.

Post curing

For air circulation oven $150\pm5^{\circ}C \times 50 \sim 80$ min

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4. ATTENTION in your process

- 1.Operation in a clean room of ambient temperature at 20 ~ 25°C / 50 ~60%RH,under yellow (UV cut) lamp avoiding fluorescent and sunlight.
- 2.For cleaning the screen, use cleaner #950 \ ester or celloslove type solvent or a mixedsolvent of ester and collosolve type.
- 3.Before use mix and stir the main component HA-8000 11G and the hardener HA-8000 W8 in a weight ratio of 750g:250g, use the ink within 48 hours after mixing.
- 4.Use an undiluted solder mask, In case of any viscisity adjustment, use the specified thenner T-8 less than 3%.
- 5.Appropriate coating thickness on copper circuits after cure is 15~25 µ m. Coating less than the said value may cause lower resistivity in solder heat, chemical and Ni/Au plating, and thicker coat may cause undercut and insufficient tackiness.
- 6. Copper foil surface treatment has a key effect on the proper functioning of solder resist inks. Therefore copper foil surface should be clean and free of oxidation absolutely. According to the degree and nature of the tarnish layer, select micro etching, mechanical brushing or both to ensure removal of any tarnish. Then rinse sufficiently with water and dry properly. Avoid treated surface to be touch by hand or come into contact with oil, grease or any dirty surface.
- 7. As curing condition and window are variable depending on the type of drying oven, the board curing may degrade the properties of coating film.
- 8. As exposure energy is variable depending on material type of substrates (UV absorbent, imide-type material, etc.) and on coating thickness, prior testing on resolution (no undercut), surface gloss level and shoot-through, etc. should be conducted to set the optimum condition.
- 9. Control well the quality of developing agent in its density, temperature, spray pressure and dwelling time. Insufficient control may cause deterioration in developability or undercut.
- 10.If contact with eyes or skin, rinse with plenty of water. Do not wash with any solvent.
- 11. Use this ink in places to avoid any fire or flame.
- 12. Store the ink in a cool place between $10^{\circ}C \sim 25^{\circ}C$.

5.CHARACTERISTICS

1.Tack dry window:

| Precure | time/min | 10 | 20 | 30 | 40 | 50 | 60 | 70 | 80 | 90 | 100 | 110 | 120 |
|-----------|----------|----|------------|------------|------------|------------|------------|------------|------------------|------------------|------------|------------------|-----|
| ty) | 80°C | × | \bigcirc | \bigcirc | \bigcirc | \bigcirc | \bigcirc | \bigcirc | \bigtriangleup | × | × | × | × |
| elopabili | 75°C | × | \bigcirc | \bigtriangleup | × | × | × |
| (Deve | 70°C | × | \bigcirc | \bigcirc | \bigcirc | \bigtriangleup | × |

2.Life after coating:

Precure condition 75°C/40min,kept in 20°C/60%RH

| Holding time /hour | 24 | 48 | 72 | 96 | 120 |
|--------------------|----|----|------------------|----|-----|
| Developability | 0 | 0 | \bigtriangleup | × | × |

3.Photo properties:

| lten | n | Coating thickness | Exposing energy | Developing time | Photo sensitivity |
|-------------------|-----------------------------|-------------------------|----------------------------------|-----------------|-------------------------|
| Pot sen Koo | o isitivity: dak No.2 | $22\pm2~\mu$ m | 400mJ/cm 500mJ/cm 600mJ/cm | 1min | 9 10 11 |
| | | | | | |
| Res (QF | solution P) | $35\pm2~\mu$ m wet film | 400mJ/cm 500mJ/cm 600mJ/cm | 1min | 50 μm 50 μm 50 μm |
| | | | | | ○ Passed |

Exposing energy in the upper columns indicate values under mylar film

 \bigtriangleup Little dross

 \times Dross

4. Viscosity Data

11G & W8 Holding time and Viscosity change







6.PROPERTIES

| 1. Physical Properties | | | | | | |
|--------------------------|------------------------------------|---|--|--|--|--|
| ITEM | RESULT | TEST METHOD | | | | |
| 1.Film hardness | 7H | JIS K5400 8.4 Pencil scratching test Pencil:Mitsubishi pencil,Coated film on copper and base material | | | | |
| 2.Abrasion resistance | No abnormality in cured film | IPC-SM-840B 3.5.1 * Taber method 3.5.1.1 Testing method manual TM 2.4.27.1 : There shall be no film reduction in excess of 25 µ m at copmpletion of 50 cycle of abration *Pencil method 3.5.1.2 Testing method manual TM2.4.27.2 : To be above F | | | | |
| 3.Adhesion | 100/100 | JIS D0202 4.15 Crosscut adhesion test JIS K5400 8.5 Cellophane adhesive tape : JIS Z 1522 width: 12mm Coated film on copper and base material | | | | |
| 4.Adhesive property | No abnormality in cured film | IPC-SM-840B 3.5.2 Rigid base plate 3.5.2.1 Testing method manual TM2.4.28.1 | | | | |
| 5.Cutting property | No abnormality in cured film | IPC-SM-840B 3.5.3 No crack or rent shall develop on the film, when visually examined at drilling, sawing and press punching operations | | | | |
| 2. Chemical Prop | erties | | | | | |
| 1.Solvent resistance | No abnormality in cured film | IPC-SM-840B 3.6.1 or JIS K5400 8.24 No blister,separation, swelling or color change shall occur on the film Isopropanol room temperature 60 min. 1.1.1 Trichroloethane room temperature 60 min. 4% ethyalcohol [,] 96% trichlorotrifluoroethane in the vapor 10 min. | | | | |

| 2.Chemical | No | JIS K5400 8.22 &8.2 | 3 |
|------------|---------------|---------------------|--------------------------|
| resistance | abnormality | 10 wt. % HCI | room temperature 30 min. |
| | in cured film | 10 wt. % H2SO4 | room temperature 30 min. |
| | | 10 wt % NaOH | room temperature 60 min. |
| | | | |

| ITEM | RESULT | TEST METHOD |
|---|------------------------------------|---|
| 3.Hydrolysis resistance | No abnormality in cured film | PC-SM-840B 3.6.2 CLASS 1 35°C 90% RH 4 days CLASS 2 85°C 90% RH 7 days CLASS 3 97°C 90% RH 28 days to be free from any change in appearance and from sticky surface |
| 4.Adhesion after boilling | No abnormality in cured film | JIS D0202 4.15 100°C 5 hours |
| 5.Adhesion after treatment in pressure cooker | No abnormality in cured film | JIS D0202 4.15 121°C 2 atmosphere pressures 5 hours |
| 3. Solder Properti | es | |
| 1.Solder resistance & Solderability | No abnormality in cured film | IPC-SM-840B 3.7 *Solder resistance 3.7.2 No deterioration shall occur in the film after application of flux and dipping for 10sec. In solder bath of 255 ± 5°C 4.8.9.1 * Solderability and peeling property .3.7.3 Perform soldering and peeling of rinned lead wire twice using solder, The result shall be satisfactory |
| 2.Solder heat resistance | No abnormality in cured film | JIS C 6481 5.5 No blister and separation on cured film Appearance : Separation test by tape peeling Flux : soldering temperature 260°C, 10 sec. , immersion 3 times ∘ |
| 3.Hot air leveler resistance | No abnormality in cured film | No blister and separation on cured film Appearance : Separation test by tape peeling Flux : Duration of immersion : 4 sec. Soldering temperature 260°C Hot air temperature 220°C Pressure : 3.8Kgs / cm ² immersion 3 times |

| ITEM | RESULT | TEST METHOD |
|---|---|---|
| 4.Thermal Shock | No abnormality in cured film | IPC-SM840C 3.4.10 and IPC-TM-650 2.6.7.3 $65^{\circ}C \times 15min+125^{\circ}C \times 15min$, 100cycles, transfer time less than 2 minutes |
| 4.Electrical Prope | erties | |
| ITEM | RESULT | TEST METHOD |
| 1.Dielectric strength | 2500V DC / mil | IPC-SM-840B 3.8.1 500V DC / mil more than 500V DC/mil |
| 2.Volume | $1 \times 10^{15} \Omega$ resistivity | JIS C6481 5.9 |
| 3. Surface resistance | $1 \times 10^{15} \Omega$ | JIS C6481 5.10) |
| 4.Insulation resistance | $ \begin{array}{c} 1 \times 10^{14} \Omega \\ 1 \times 10^{14} \Omega \\ 1 \times 10^{14} \Omega \\ 1 \times 10^{14} \Omega \end{array} $ | TPC-SM-840B 3.8.2 JIS C6481 5.11 CLASS1 35°C 90%RH 4 Applied voltage110V $\ge 5 \times 10^{8} \Omega$ CLASS2 50°C 90%RH 7 Applied voltage110V $\ge 5 \times 10^{8} \Omega$ CLASS3 25°C ~65°C90%RH 7 Applied voltage110V $\ge 5 \times 10^{8} \Omega$ 1 Cycle 8±1/4 Hour |
| 5.Dielectric loss tangent (Tan δ) | 0.03 1 MHz | JIS C 6481 5.12 Impedance analyzer |
| 6.Dielectric factor (ε) | 3.5 1 MHz | JIS C 6481 5.12 Impedance analyzer |
| 7.Electrochemical | Resistance ≧ 2 megohms | IPC-SM840C 3.4.10 85°C±2°C,90%RH,168hrs,Bias voltage 10VDC |

* All test data mentioned above in this technical data sheet and example of operation process are based on our test result and only for reference, not to guarantee the same in your process.

7. CAUTION

All chemicals used in this product might have unknown toxicity. Please handle with your most care referring to the Product Guide and MSDS for use.